

Synergistic Effects of Dual-Electrocatalyst FeOOH/NiOOH Thin Films as Effective Surface Photogenerated Hole Extractors on a Novel Hierarchical Heterojunction Photoanode Structure for Solar-driven Photoelectrochemical Water Splitting

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Abstract

Herein, we report the rational design of a novel hierarchical $\text{V}_2\text{O}_5/\text{BiVO}_4$ heterojunction photoanode structure with rGO interlayer that functionalises as photogenerated electron collector, and dual electrocatalyst thin films of FeOOH and NiOOH as photogenerated hole extractors for solar-driven PEC water splitting. Results showed that the novel hierarchical FTO/ $\text{V}_2\text{O}_5/\text{rGO}/\text{BiVO}_4/\text{FeOOH}/\text{NiOOH}$ photoanode exhibited an unprecedented and stable photocurrent density of 3.06 mA/cm^2 at 1.5 V vs Ag/AgCl , and an apparent cathodic onset potential shift down to 0.2 V under AM 1.5 G simulated solar light illumination. The significant enhancement in PEC performance is ascribed to band potentials matching between V_2O_5 and BiVO_4 in forming a Type II staggered heterojunction alignment, and further coupling with rGO interlayer and dual-electrocatalyst thin films as photogenerated electron collector and photogenerated hole extractors, respectively. Three different configurations of the novel hierarchical FTO/ $\text{V}_2\text{O}_5/\text{rGO}/\text{BiVO}_4$ photoanodes without electrocatalyst, with mono- and dual-electrocatalyst thin films were systematically examined. It was proven though EIS and IMPS measurements that the dual-electrocatalyst configuration photoanode exhibited the shortest transit time (τ) of 31.8 ms for the diffusion of photogenerated electrons to the counter electrode, and the lowest charge transfer resistance across the interface of electrode/electrolyte as estimated using the Randles-Ershel model. We believe that the proof-of-principle work described here not only provides an in-depth understanding on the roles of electrocatalyst thin films but also provides a design guide over the incorporation of electrocatalyst materials for further improving the photogenerated charge carrier dynamics in photoanodes used in solar-driven PEC water splitting.

KEYWORDS: Bismuth vanadate; Heterojunction; Reduced graphene oxide; Electrocatalysts; Photoelectrochemical water splitting

1. Introduction

Since the discovery of the Honda-Fujishima effect, overwhelming attention has been focused on the photoelectrochemical (PEC) water splitting by harnessing solar energy to directly dissociate water molecules into renewable hydrogen (H_2) fuels and oxygen (O_2) molecules [1]. At the core of PEC water splitting system for solar-to-hydrogen (STH) energy conversion is the semiconductor-based photoelectrodes used, which absorb solar photons resulting in the formation of photogenerated charge carriers (i.e. electrons and holes) [2-5]. In principle, the PEC water splitting reaction involves oxygen evolution reaction (OER) at the photoanode (Eq. 1) and hydrogen evolution reaction (HER) at the photocathode (Eq. 2).



Over the last five decades, various semiconductor materials have been studied in addition to the titanium dioxide (TiO_2) for application in PEC water splitting for solar H_2 fuels production. To date, however, there is no singular semiconductor material that met the ideal requirements for application in practical PEC water splitting such as having high stability under the operating conditions, high STH efficiency, and cost inexpensiveness [6-8]. Among all, bismuth vanadate ($BiVO_4$) is regarded as one of the most promising photoanode materials used for PEC water splitting. Ideally, $BiVO_4$ fulfills many of practical requirements for PEC water splitting for solar H_2 fuels production, such as having relatively narrow band gap ~ 2.5 eV that absorbs a substantial portion of visible light spectrum, earth abundance, low cost, environmentally benign and possesses a favourable conduction band (CB) edge position that is very near to the thermodynamic H_2 evolution potential [9, 10]. Whilst in terms of the charge carriers dynamics, the effective mass of photogenerated charge carriers in $BiVO_4$ is much lighter than other photoactive semiconductor materials. This implies that they have a higher probability to reach the surface reaction sites within their exciton lifetime [11].

Thus far, the practical efficiency of PEC water splitting using singular $BiVO_4$ photoanode is still far from its theoretical maximum photocurrent density of 7.5 mA/cm^2 under AM 1.5 G illumination [12]. This is due to the excessive recombination of electron-hole pairs, poor charge transport properties and high surface reaction kinetic barriers when using the singular $BiVO_4$ photoanode in PEC water splitting [13, 14]. Recently, Zachäus and co-workers reported that the generation of photocurrent on $BiVO_4$ photoanode is not limited by its surface

reaction kinetics but surface recombination of photogenerated charge carriers [15]. Furthermore, BiVO₄ photoanode suffers from both chemical and photochemical instability under aqueous condition [16]. In order to overcome these issues, the effective separation and transfer of the photogenerated charge carriers within the photoanode structure is crucial. Proper band potentials alignment and hybridisation of functionalised thin films within the heterojunction photoanode structure to extract both the photogenerated charge carriers out of the bulk BiVO₄ are an effective way to mitigate the issues associated with surface recombination and photostability [17, 18].

One of the common approaches to extract photogenerated holes from bulk BiVO₄ is by introducing either oxygen evolution reaction (OER) or hydrogen evolution reaction (HER) electrocatalyst to reduce the interfacial charge carriers recombination at the semiconductor/OER junction while creating a more favorable Helmholtz layer potential drop at the OER/electrolyte junction [19-21]. Theoretically, the introduction of OER electrocatalyst onto photoanode structure is inherently more complex and may result in a higher efficiency loss than when introducing HER electrocatalyst. This is due to that OER requires four-electrons transfer step with the removal of four protons from water molecules to generate one O₂ molecule and thus, leading to a large overpotential requirement to facilitate the reaction efficiently [19, 22]. To date, the most commonly used OER electrocatalysts on photoanode for PEC water splitting are precious noble metals oxides, such as ruthenium (IV) oxide (RuO₂) and iridium (IV) oxide (IrO₂) [23]. Nevertheless, the utilisation of OER electrocatalysts loaded onto photoanode for large-scale practical PEC water splitting is constrained by the resource-scarcity of noble metals and their high-cost [24]. Balsara et al. found that the first row transition metal-based OER cocatalysts are very promising candidates due to their high stability, abundance in nature, low-cost and advanced catalytic performance that is comparable to the noble metal-based OER cocatalysts [25, 26]. With the introduction of OER cocatalysts, it is expected to provide active sites for interfacial reaction with reducing overpotential requirement, enhanced PEC stability through efficient extraction of photogenerated charge carriers from bulk semiconductor and a physical thin film barrier that protects the bulk semiconductor surface from direct contact with electrolyte used [27, 28].

Herein, in this study, we report a rational design of a novel hierarchical vanadium pentoxide (V₂O₅)/BiVO₄ heterojunction photoanode structure with reduced graphene oxide (rGO) interlayer on fluorine-doped tin oxide (FTO) substrate and topping with dual transition-metal electrocatalyst thin films of ferric (FeOOH) and nickel oxyhydroxide (NiOOH) for

improving the overall efficiency for solar-driven PEC water splitting. V_2O_5 has been intensively investigated as a superior candidate for stimulating the water oxidation reaction with a band gap of 2.3- 2.8 eV for solar capturing and an appropriate band energy level for PEC water splitting [29]. The band potentials matching between V_2O_5 and $BiVO_4$ enables the formation of a Type II staggered heterojunction photoanode that allows more photogenerated electrons to reach the counter electrode and more photogenerated holes to reach the surface of $BiVO_4$ [29, 30]. Whilst further coupling with rGO interlayer promotes efficient interfacial charge transfer and reduce the electron injection barrier between V_2O_5 and $BiVO_4$. Additionally, the synergistic effects of introducing dual electrocatalyst thin films of $FeOOH$ and $NiOOH$ as efficient photogenerated hole extractors were also examined. In particular, the charge carriers separation and injection properties of the novel hierarchical photoanode were investigated in the presence of hole scavenger, hydrogen peroxide (H_2O_2) with facile oxidation kinetics. Both electrochemical impedance spectroscopy (EIS) and intensity-modulated photocurrent spectroscopy (IMPS) measurements were performed to gain an insight into the transport of photogenerated charge carriers, recombination processes and kinetics of PEC water splitting reactions at the interfacial of heterojunction photoanode structure. This study will provide a new insight on the rational design of heterojunction photoanode structure with hybridised thin films that act as both photogenerated electron collector and hole extractor, and the synergistic effects that arise through the formation of novel hierarchical heterojunction photoanode structure for PEC water splitting.

2. Experimental Section

2.1. Materials

Vanadium (IV) oxide sulfate hydrate ($VOSO_4$, 97%) was obtained from Sigma Aldrich, USA. Nitric acid (HNO_3 , 69%) and anhydrous sodium acetate (CH_3COONa) were obtained from Friendemann Schmidt Chemical, Germany; absolute ethanol (C_2H_6O), hydrogen peroxide (H_2O_2) (30 wt%), sulfuric acid (H_2SO_4) (96 wt%), phosphoric acid (H_3PO_4) (75 wt%), potassium permanganate ($KMnO_4$), hydrochloric acid (HCl) (30 wt%), graphite powder, iron (III) sulphate heptahydrate ($FeSO_4 \cdot 7H_2O$), nickel (III) sulphate hexahydrate ($NiSO_4 \cdot 6H_2O$), sodium hydroxide ($NaOH$) and sodium sulfate (Na_2SO_4) were purchased from Merck, Germany. Bismuth nitrate pentahydrate ($Bi(NO_3)_3 \cdot 5H_2O$) was purchased from R&M Chemicals, United Kingdom. FTO glass was purchased from Kaivo Optoelectronic

Technology, China. The FTO glass substrate ($14 \Omega/\text{sq}$) was cut and cleaned using acetone, ethanol and deionised water in an ultrasonic bath for 20 min. All the reagents were of analytical grade and used without further purification.

2.2 Preparation of $\text{V}_2\text{O}_5/\text{BiVO}_4$ heterojunction photoanode with rGO interlayer

Graphene oxide (GO) was prepared *via* the Improved Hummers' method due to its facile and cost-effective synthesis procedures. Briefly, a thin film of GO was coated onto the FTO substrate through drop-casting 240 μL of the 0.5 mg/mL GO dispersion. This was followed by the electrodeposition of V_2O_5 thin film onto the GO-coated FTO substrate. The electrodeposition of V_2O_5 thin film was carried out by applying 1.5 V vs Ag/AgCl (3M) for 10 min using a precursor aqueous solution containing 0.2 M VOSO_4 and 20 mL ethanol at pH 1.8 adjusted using 95-99 % H_2SO_4 . The FTO/ V_2O_5 samples were annealed at 400 °C for 1 hr. To prepare the subsequent rGO interlayer on the annealed FTO/ V_2O_5 samples, 320 μL of 0.5 mg/mL GO dispersion was drop-casted on top of V_2O_5 thin film followed by electrochemical reduction of GO at an applied bias range of -1.5 to 0.5 V vs Ag/AgCl for 4 cycles in 0.1 M Na_2SO_4 electrolyte. The final BiVO_4 thin film was prepared on top of the rGO interlayer following a modified electrodeposition method [31]. Specifically, 10 mM $\text{Bi}(\text{NO}_3)_3$ and 35 mM VOSO_4 were separately dissolved in 0.5 M HNO_3 as the Bi and V precursor solutions, respectively. The pH value of the electrolyte was raised to pH 5.1 using 2 M CH_3COONa , and then adjusted to a final pH of pH 4.7 using 69 % HNO_3 . The electrodeposition was carried out potentiostatically at 1.9 V vs Ag/AgCl for 45 min. Finally, the as-deposited films were rinsed and then annealed at 400 °C for 1 hr in air environment.

2.3 Electrodeposition of FeOOH and photo-assisted electrodeposition of NiOOH

A thin film of FeOOH was conformally electrodeposited on the FTO/ $\text{V}_2\text{O}_5/\text{rGO}/\text{BiVO}_4$ heterojunction photoanode from a 0.1 M $\text{FeSO}_4 \cdot 7\text{H}_2\text{O}$ aqueous solution by applying an external bias of 0.65 V vs Ag/AgCl (3M KCl). The electrodeposition synthesis process was halted after it has exceeded the total charge threshold of 0.42 mC/cm². During the electrodeposition synthesis process, Fe^{2+} ions were oxidised to Fe^{3+} ions that precipitated out as FeOOH on top of BiVO_4 thin film. As for the photo-assisted electrodeposition synthesis of NiOOH, the FTO/ $\text{V}_2\text{O}_5/\text{rGO}/\text{BiVO}_4/\text{FeOOH}$ heterojunction photoanode was transferred to a three-

electrode PEC cell containing 0.5 M NiSO₄.6H₂O in which the pH was adjusted to pH 7 by using 1 M NaOH. A 150 W Xenon light with an output intensity of 100 mW/cm² was used as the illumination source for solar-driven PEC water splitting (Abet Technologies Model 10500, United States). During the illumination, Ni²⁺ ions were oxidised to Ni³⁺ ions that precipitated out as NiOOH on top of FeOOH thin film. To facilitate the photo-assisted electrodeposition synthesis of NiOOH, an external bias of 0.4 V vs Ag/AgCl was applied. The photo-assisted electrodeposition process was stopped after a total charge of 0.6 μC/cm² was attained.

2.4 Characterisation

The prepared photoanodes were characterised by using X-ray powder diffraction (XRD) on a Bruker D8 Discover diffractometer (Hitachi SU8010, Japan) equipped with Ni-filtered Cu-Kα radiation at the scan rate of 0.02° s⁻¹. The measurements were collected using an accelerating voltage and applied current of 40 kV and 40 mA respectively to obtain its crystalline phase composition. Electron transparent focused ion beam (FIB) lamellae were prepared by using a FEI Nova 200 Nanolab Dual Beam FIB instrument from United States. A final clean was performed using a 5 kV gallium beam, while a 12 pA gallium beam was used to remove the material deposited during FIB preparation as well as to reduce damage from the initial milling process. This was followed by low energy argon cleaning. A thin film of electron beam-deposited platinum followed by a gradient of fine-to-coarse grained ion beam platinum were deposited to minimise the ion beam interaction with the exposed surface throughout the transmission electron microscopy (TEM) sample preparation.

UV-vis diffuse reflectance spectra were recorded on a UV-vis spectrophotometer (Agilent Cary 100, United States) equipped with an integrated sphere. X-ray photoelectron spectroscopy (XPS) measurements were performed using a scanning X-ray microprobe PHI Quantera II (Ulvac-PHI, INC.) with a monochromatic Al-Kα ($h\nu = 1486.6$ eV) X-ray source. Linear sweep voltammetry (LSV), IMPS, cyclic voltammetry and EIS were measured in a three-electrode cell system using an applied potentiostat/galvanostat (Metrohm PGSTAT 204 model, Netherlands), where the Pt rod and a saturated Ag/AgCl (3M) were used as counter and reference electrode, respectively. Nyquist analyses were acquired with a frequency range of 100 kHz–0.1 Hz at 1.2 V bias voltage with FRA32M frequency analyser (Metrohm-Autolab, The Netherlands). Mott-Schottky analyses were performed at 10 kHz by scanning the potential range from -0.1 to 0.9 V at 0.05 V s⁻¹ sweep rate. IMPS measurements were conducted using

a potentiostat connected to a high intensity light emitting diode (cool white LED) controlled by LED driver that allowed the superimposition of sinusoidal modulation on a DC illumination level. The light intensity was modulated by 10 % between 10 kHz and 0.1 Hz.

3. Results and Discussion

XRD measurements were carried out and shown in Fig. 1 (a) to examine the phase purity of a series of as-prepared photoanodes along with the information on their crystalline structure. The XRD pattern of the FTO/V₂O₅/BiVO₄ heterojunction photoanode structure demonstrated that the BiVO₄ existed in its monoclinic scheelite phase (JCPDS Card No. 14-0688) and V₂O₅ in its orthorhombic phase (JCPDS Card No. 72-433) [32]. Meanwhile, the XRD peaks at 38, 51.7, 61.8, 65.7 ° for all the photoanode structures were ascribed to the FTO substrate used [33]. There are no distinct XRD diffraction peaks that can be observed in the novel hierarchical FTO/V₂O₅/rGO/BiVO₄ photoanode with the dual-electrocatalyst thin films due to the amorphous nature of both the FeOOH and NiOOH thin films. However, both the EDX elemental mapping and XPS analysis revealed the existence and distribution of Fe and Ni element on the outermost surface of FTO/V₂O₅/rGO/BiVO₄ photoanode. The cross-sectional low magnification TEM image shown in Fig. 1 (b) reveals the uniform dispersion of both Fe and Ni elements over BiVO₄ of the FTO/V₂O₅/rGO/BiVO₄ photoanode. Fig. 1 (c) and (d) show the Fe 2p and Ni 2p XPS spectra with major peaks of 712.6, 726.3, 856.3 and 874.3 eV, respectively, which are a good evidence to validate the presence of FeOOH and NiOOH thin films [34, 35].

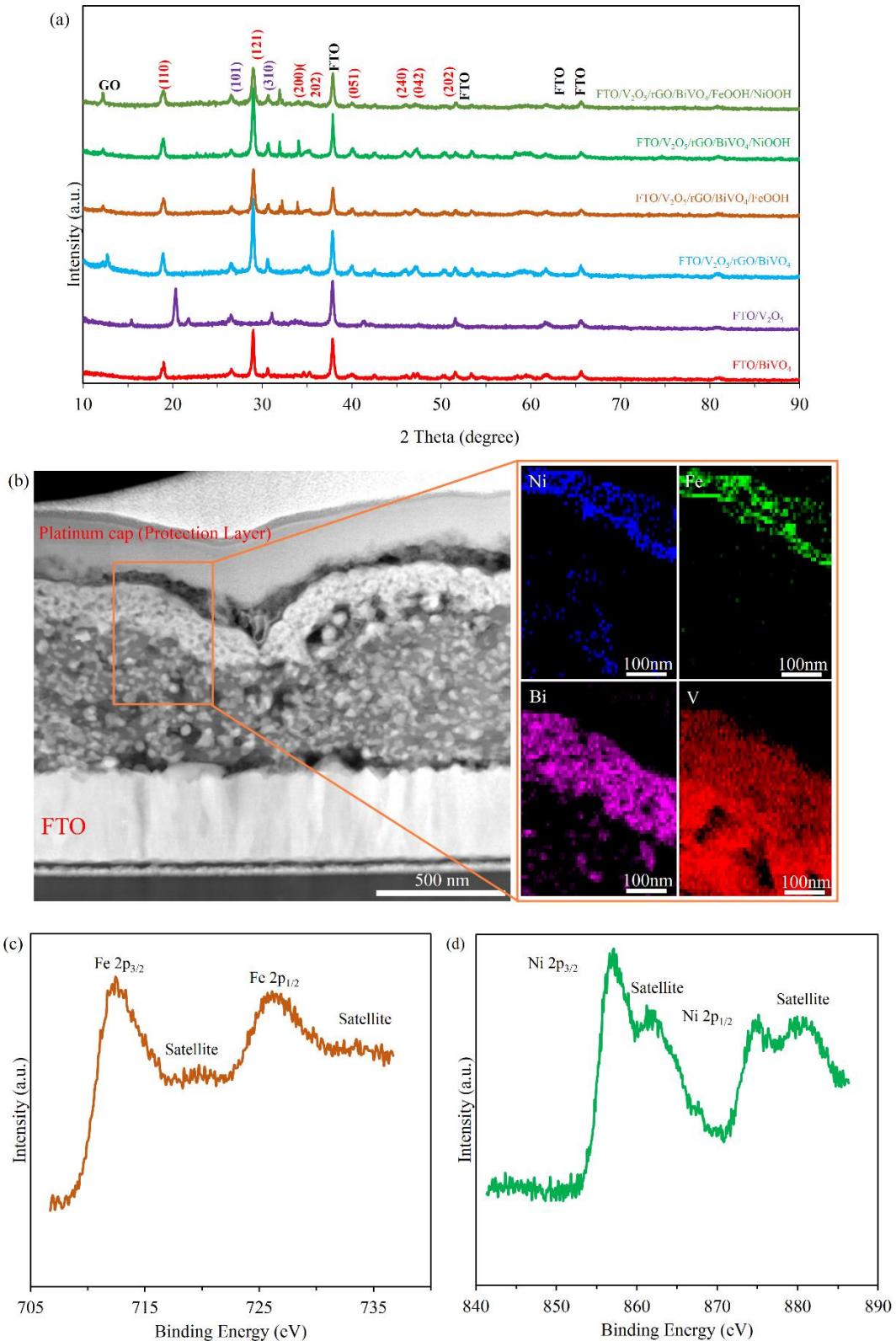


Fig. 1. (a) XRD patterns of the as-prepared photoanode structures. (b) Element mapping and XPS spectra of (c) Fe 2p and (d) Ni 2p for hierarchical FTO/V₂O₅/rGO/BiVO₄/FeOOH/NiOOH photoanode.

The optical band gap energies of the monoclinic BiVO_4 scheelite phase and orthorhombic V_2O_5 phase can be determined from the plot of Kubelka-Munk function ($\alpha h\nu)^2$ versus incident light energy ($h\nu$), where α is absorption co-efficient in cm^{-1} , h is the Planck constant (6.626×10^{-34} J.s) and ν is the frequency of light (Hz) [36]. By extrapolating a linear line of the curve that meets at the x-axis intercept, the optical band gap energies of BiVO_4 and V_2O_5 are determined to be 2.55 eV and 2.49 eV as shown in Fig. 2(a) and (b), respectively. Fig. 2 (c) illustrates the optical property of FTO/ BiVO_4 , FTO/ $\text{V}_2\text{O}_5/\text{rGO}/\text{BiVO}_4$ and FTO/ $\text{V}_2\text{O}_5/\text{rGO}/\text{BiVO}_4/\text{FeOOH}/\text{NiOOH}$ photoanodes as measured by using UV-vis diffuse reflectance spectrophotometer. With the construction of heterojunction photoanode structure between BiVO_4 and V_2O_5 as well as the introduction of rGO interlayer, the light absorption ability in the visible region was increased from 495 nm to 585 nm. When the heterojunction photoanode structure of FTO/ $\text{BiVO}_4/\text{V}_2\text{O}_5$ was constructed, two shoulders were observed in its light absorption profile that corresponded well to the absorbance of BiVO_4 and V_2O_5 . It was, however that no absorption edge was observed indicating the rGO interlayer in the current system does not have an energy gap [37]. In comparison to the FTO/ $\text{V}_2\text{O}_5/\text{BiVO}_4$ heterojunction structure with rGO interlayer, the novel hierarchical FTO/ $\text{V}_2\text{O}_5/\text{rGO}/\text{BiVO}_4/\text{FeOOH}/\text{NiOOH}$ photoanode was demonstrated to have a broadened light absorption range and enhanced light absorption intensity which are beneficial for the wider utilisation of the solar spectrum.

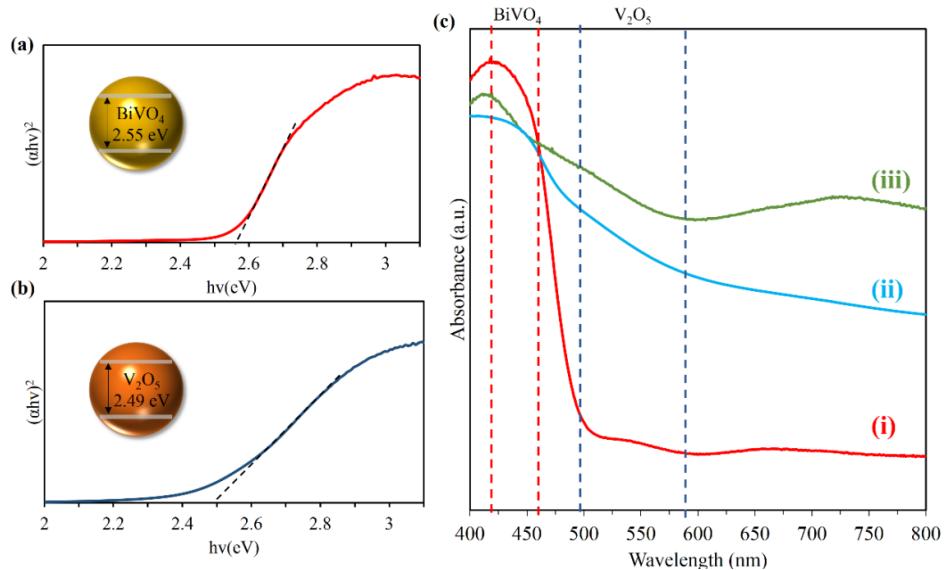


Fig. 2. Tauc plot of pristine (a) BiVO_4 and (b) V_2O_5 , (c) UV-vis diffuse reflectance spectra for (i) FTO/ BiVO_4 , (ii) FTO/ $\text{V}_2\text{O}_5/\text{rGO}/\text{BiVO}_4$ and (iii) FTO/ $\text{V}_2\text{O}_5/\text{rGO}/\text{BiVO}_4/\text{FeOOH}/\text{NiOOH}$.

In this study, all the PEC analysis was performed using the standard three-electrode configuration in 0.5 M Na₂SO₄ electrolyte solution. Fig. 3 (a) shows the photocurrent density-potential curves of FTO/BiVO₄, FTO/V₂O₅/BiVO₄, FTO/V₂O₅/rGO/BiVO₄, FTO/V₂O₅/rGO/BiVO₄/FeOOH, FTO/V₂O₅/rGO/BiVO₄/NiOOH and FTO/V₂O₅/rGO/BiVO₄/FeOOH/NiOOH photoanode structures under AM 1.5 G simulated solar light illumination. All the LSV curves were examined for two prominent features, namely; (1) photocurrent density measured at 1.5 V vs Ag/AgCl, and (2) photocurrent onset potential. As shown in Fig. 3 (a), the pristine BiVO₄ exhibits a very low photocurrent density of only 0.25 mA/cm² at 1.5 V vs Ag/AgCl under front illumination. With the construction of FTO/V₂O₅/rGO/BiVO₄ heterojunction structure, a significantly improved photocurrent density of 9-fold higher than that of pristine BiVO₄ was observed and reaching a photocurrent density of 2.1 mA/cm² at 1.5 V vs Ag/AgCl. When a thin film of FeOOH and NiOOH electrocatalyst was decorated on top of the FTO/V₂O₅/rGO/BiVO₄ photoanode structure, the measured photocurrent density was seen to increase to 2.54 and 2.59 mA/cm² at 1.5 V vs Ag/AgCl, respectively.

When compared to the mono-electrocatalyst thin film configuration of FTO/V₂O₅/rGO/BiVO₄/FeOOH and FTO/V₂O₅/rGO/BiVO₄/NiOOH, the dual-electrocatalyst configuration of FTO/V₂O₅/rGO/BiVO₄/FeOOH/NiOOH showed a more remarkable enhancement in terms of its photocurrent density. Results have distinctly showed that the dual-electrocatalyst FTO/V₂O₅/rGO/BiVO₄/FeOOH/NiOOH photoanode achieved a remarkable photocurrent density of 3.06 mA/cm² at 1.5 V vs Ag/AgCl, which was 12-fold higher than the pristine BiVO₄. The significant enhancement in photocurrent density of the novel hierarchical FTO/V₂O₅/rGO/BiVO₄/FeOOH/NiOOH photoanode is attributed to the synergistic effect of the dual-electrocatalyst configuration, in which the BiVO₄/FeOOH interface minimises electron recombination at the BiVO₄/FeOOH junction. Whilst the NiOOH/electrolyte interface makes the surface charge more favourable, and concurrently improving the overall PEC performance.

Another imperative feature of the LSV as shown in Fig. 3(a) is the photocurrent onset potential. In this instance, the photocurrent onset potential is defined as the potential at the intersection point of the tangent at a maximum slope of photocurrent and the dark current curves. From Fig. 3(a), the onset potential of FTO/V₂O₅/rGO/BiVO₄ photoanode shows a slight cathodic shift from 0.7 V to 0.6 V when compared to the FTO/V₂O₅/BiVO₄ photoanode. This observation is clearly indicating that the FTO/V₂O₅/BiVO₄ photoanode exhibited a lower

charge injection efficiency than the FTO/V₂O₅/rGO/BiVO₄ photoanode. When compared to the FTO/V₂O₅/rGO/BiVO₄ photoanode, it was observed that the photocurrent onset potential of FTO/V₂O₅/rGO/BiVO₄/FeOOH photoanode was significantly reduced from 0.6 V to 0.3 V with a cathodic shift of 0.2 V. To a greater extent, the photocurrent onset potential of the FTO/V₂O₅/rGO/BiVO₄/FeOOH photoanode was further cathodically shifted down to 0.1 V when a NiOOH thin film was decorated as the outermost layer through the photo-assisted electrodeposition synthesis. The significant cathodic shift of the photocurrent onset potential is greatly due to the reduced surface electron-hole recombination and accelerated OER activity.

In order to further validate and correlate the measured photocurrent density of the FTO/V₂O₅/BiVO₄, FTO/V₂O₅/rGO/BiVO₄ and FTO/V₂O₅/rGO/BiVO₄/FeOOH/NiOOH photoanodes are indeed originated from the water splitting activity, H₂ gas evolution measurement was carried out under AM 1.5 G simulated solar light illumination with an applied potential of 1.5 V. In this instance, the absence of the H₂ gas evolution from pristine BiVO₄ is due to the very low and disproportionate generation of photocurrent density generation of 0.22 mA/cm² at 1.5 V vs Ag/AgCl. In order to rule out that the enhanced H₂ gas evolution rate was resulted from the dual-electrocatalyst configuration, control studies were conducted in the presence of V₂O₅ and rGO interlayer under the similar working conditions. From Fig. 3 (c), the H₂ gas evolution rate for the FTO/V₂O₅/BiVO₄ and FTO/V₂O₅/rGO/BiVO₄ photoanodes are 8.17 μmol/hr and 32.7 μmol/hr, respectively. This shows that both the V₂O₅ (i.e. forming heterojunction with BiVO₄) and rGO (i.e. interlayer in V₂O₅/BiVO₄ heterojunction) play an important role in promoting the effective separation of photogenerated charge carriers through prolonging the lifetime of the photogenerated electrons. With the dual-electrocatalyst configuration, the H₂ gas evolution rate of the FTO/V₂O₅/rGO/BiVO₄/FeOOH/NiOOH photoanode was further increased to 44.96 μmol/hr. This is more superior to that of the FTO/V₂O₅/BiVO₄ and FTO/V₂O₅/rGO/BiVO₄ photoanodes by 5.5-fold and 1.4-fold, respectively. Based on these results, it is evidenced that the charge carriers separation, accumulation and recombination at the FTO/V₂O₅/rGO/BiVO₄ heterojunction interfaces as well as the charge carriers injection efficiency are improved through the novel hierarchical photoanode structure with dual-electrocatalysts configuration.

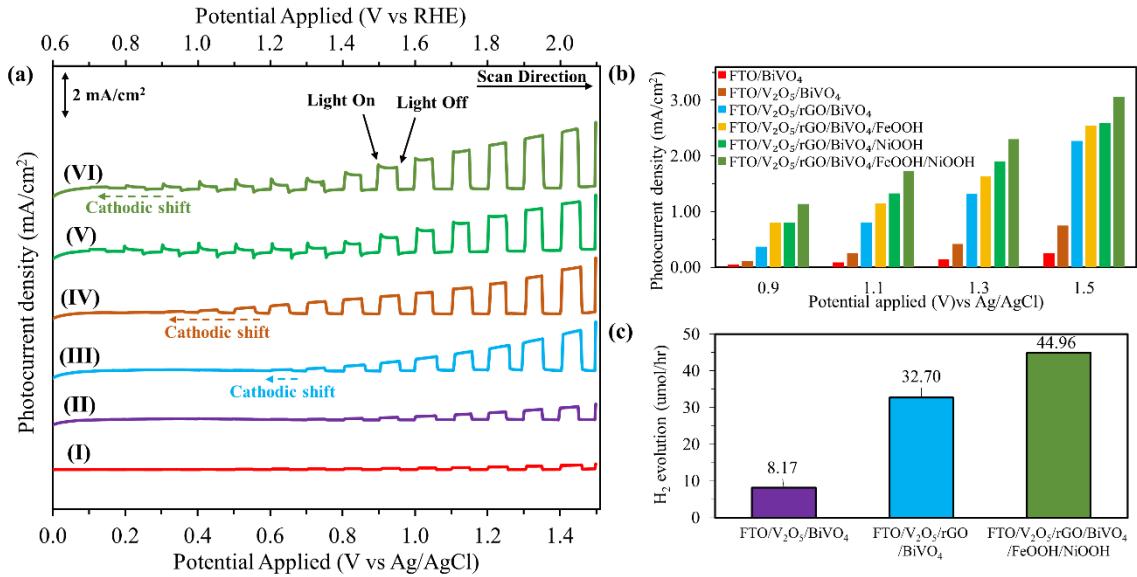


Fig. 3. (a) LSV measured with and without AM 1.5 G illumination and (b) photocurrent density measured at different applied potentials for (i) FTO/BiVO₄, (ii) FTO/V₂O₅/BiVO₄, (iii) FTO/V₂O₅/rGO/BiVO₄, (iv) FTO/V₂O₅/rGO/BiVO₄/FeOOH, (v) FTO/V₂O₅/rGO/BiVO₄/NiOOH and (vi) FTO/V₂O₅/rGO/BiVO₄/FeOOH/NiOOH photoanodes. (c) H_2 gas evolution rate from FTO/V₂O₅/BiVO₄ and FTO/V₂O₅/rGO/BiVO₄ and FTO/V₂O₅/rGO/BiVO₄/FeOOH/NiOOH photoanodes.

IMPS, a frequency-resolved optoelectric characterisation method, has been widely employed to obtain the function of applied potential in elucidating the dynamic of charge carriers transport processes [38]. This characterisation method is based on the sinusoidal modulation of illumination intensity in a wide range of frequencies with simultaneous measurement of the corresponding photocurrent responses. The lower semicircle (i.e. high frequency semicircle) provides information on the charge transport and relaxation in photoanode, whose intercept with x-axis equals to the hole current without recombination. Whilst the upper semicircle (i.e. upper frequency semicircle), also known as recombination semicircle, corresponds to the competition between interfacial charge transfer and surface recombination. In this study, IMPS was used to investigate and gain a deeper understanding in the charge separation and collection dynamics for the photoanodes under AM 1.5 G illumination. The role of FeOOH and NiOOH electrocatalyst thin films was investigated using IMPS, and the relevant IMPS responses of the FTO/BiVO₄, FTO/V₂O₅/BiVO₄, FTO/V₂O₅/rGO/BiVO₄ and FTO/V₂O₅/rGO/BiVO₄/FeOOH/NiOOH photoanodes are presented in a complex plane in Fig.

4 (a). From Fig. 4(a), it can be observed that only the pristine BiVO₄ photoanode exhibits the recombination semicircle. The absence of recombination semicircle for other photoanodes indicates the charge carrier recombination is hindered, while the charge carrier transfer is more efficient with the construction of heterojunction structure and incorporation of rGO interlayer as electron mediator as well as the dual-electrocatalyst thin films. The average lifetime for photogenerated electrons to be diffused to the counter electrode through the external circuit can be estimated by using the following equation:

$$\tau = \frac{1}{2\pi f_{min}} \quad (\text{Eq. 3})$$

where τ is the transient time, and f_{min} is the frequency at which the minimum point in the IMPS plot occurs. By using Equation (3), the τ for photogenerated electrons in FTO/V₂O₅/rGO/BiVO₄, FTO/V₂O₅/rGO/BiVO₄/FeOOH, FTO/V₂O₅/rGO/BiVO₄/NiOOH and FTO/V₂O₅/rGO/BiVO₄/FeOOH/NiOOH photoanodes was estimated and as shown in Fig. 4 (b). From Fig. 4 (b), both the FTO/V₂O₅/rGO/BiVO₄ and FTO/V₂O₅/rGO/BiVO₄/FeOOH photoanodes show a relatively longer and same τ of 100.42 ms when compared to FTO/V₂O₅/rGO/BiVO₄/NiOOH and FTO/V₂O₅/rGO/BiVO₄/FeOOH/NiOOH photoanodes with τ of 50.3 ms and 31.8 ms, respectively. A shorter τ suggests the photogenerated electrons are effectively diffused to the counter electrode with a low fraction of photogenerated electrons being recombined. This finding is in concordant to the measured photocurrent density and H₂ gas evolution rate shown in Fig. 3.

Fig. 4 (c) shows the photoluminescence (PL) spectra of FTO/BiVO₄, FTO/V₂O₅/rGO/BiVO₄ and FTO/V₂O₅/rGO/BiVO₄/FeOOH/NiOOH photoanodes. Similarly, PL is an indicator tool to reveal the charge carrier trapping, migration and recombination processes in PEC photoanodes. The stronger PL spectrum intensity means that the photogenerated electrons and holes are prone to the recombination process, and the lifetime of the photogenerated electrons is short. In contrast, if the lifetime of the photogenerated electrons could be prolonged, the intensities of the luminous peaks in the corresponding PL spectrum will be very weak. From Fig. 4 (c), all the studied photoanodes exhibit similar PL spectra shapes with two luminous peaks at 483 nm and 534 nm. The luminescence peak at 483 nm corresponds to the recombination of photogenerated hole formed in the O_{2p} band and the photogenerated electron in the V_{3d} band, while the luminescence peak at 534 nm is due to the crystalline defects of BiVO₄ [39]. Among all, the dual-electrocatalyst configuration photoanode of FTO/V₂O₅/rGO/BiVO₄/FeOOH/NiOOH achieved the lowest PL intensity

which implied that the photogenerated electron–hole pairs possessed the highest transfer efficiency among the studied photoanodes.

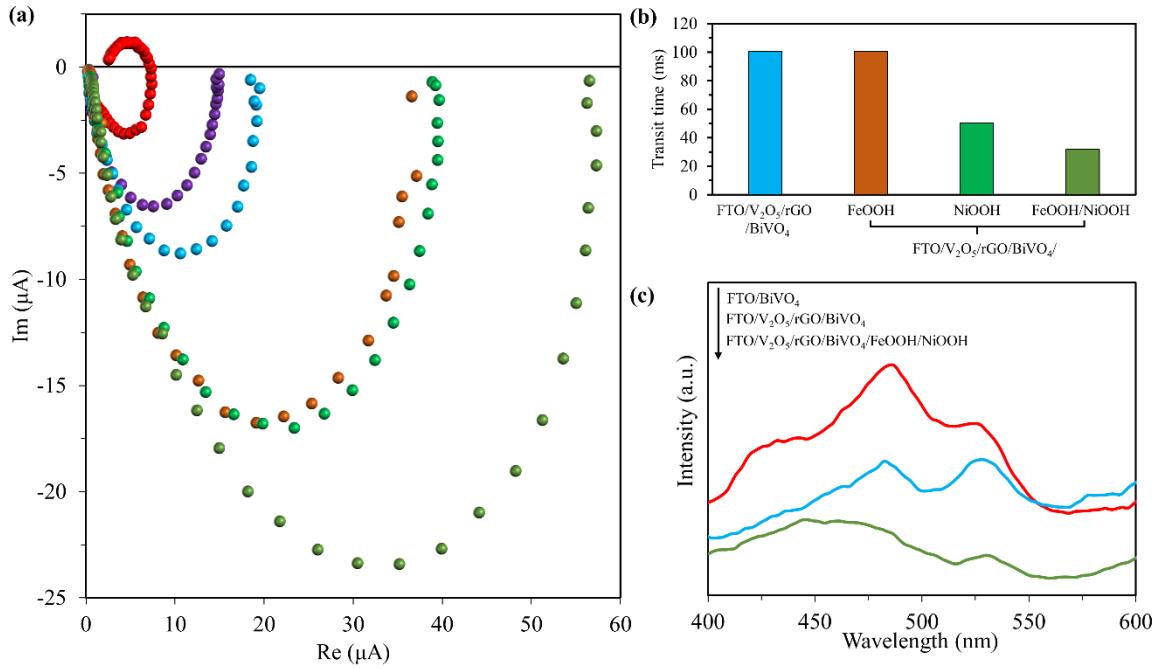


Fig. 4. (a) IMPS spectra measured at an applied potential of 1 V vs Ag/AgCl. (b) Transient time for photogenerated charges to reach the back contact of a photoanode. (c) PL spectra of the as-prepared photoanodes at room temperature. FTO/BiVO₄ (●), FTO/V₂O₅/BiVO₄ (●), FTO/V₂O₅/rGO/BiVO₄ (●), FTO/V₂O₅/rGO/BiVO₄/FeOOH (●), FTO/V₂O₅/rGO/BiVO₄/NiOOH (●) and FTO/V₂O₅/rGO/BiVO₄/FeOOH/NiOOH (●).

In order to further understand the kinetics of solar-driven PEC water splitting process in the presence of FeOOH and NiOOH electrocatalyst thin films on the V₂O₅/rGO/BiVO₄ photoanode, EIS analysis was performed using a three-electrode configuration with AM 1.5 G illumination to investigate the potential reasoning on significantly enhanced photocurrent density and H₂ gas evolution rate. Fig. 5 (a) shows the Nyquist plot consisting of experimental data (in dotted form) and fitted solid lines to the equivalent circuit (shown in the inset) by using the Metrohm Autolab NOVA software. EIS analysis in the form of Nyquist plot involves designing an equivalent circuit of capacitors and resistances that can represent the semiconductor-electrolyte interface, in order to gain a deeper insight into the interfacial charge transfer behavior in PEC cell. In Fig. 5 (a), the x-axis represents the real part of measured impedance while the y-axis represents the negative number of the imaginary part of measured

impedance. The Randles-Ershel fitting model was used in this study, where series resistance (R_s) is the solution resistance, constant phase element (Q) is capacitance associates with the Helmholtz layer at the electrode-solution interface, and charge-transfer resistance (R_{ct}) is the charge transfer resistance across the interface of electrode/electrolyte.

Results showed that the mono-electrocatalyst configuration of FTO/V₂O₅/rGO/BiVO₄/FeOOH and FTO/V₂O₅/rGO/BiVO₄/NiOOH photoanodes were successful in reducing the R_{ct} from 224.7 Ω (i.e. for FTO/V₂O₅/rGO/BiVO₄) to 140.8 Ω and 107.8 Ω, respectively. A smaller R_{ct} value signifies an improved charge carrier transport across the electrode-electrolyte interface of the mono-electrocatalyst configuration photoanodes and thus, dramatically suppresses the electron-hole recombination and making favourable environment for PEC water splitting reactions. Additionally, the dual-electrocatalyst configuration photoanode of FTO/V₂O₅/rGO/BiVO₄/FeOOH/NiOOH was also analysed and fitted using the EIS Randles-Ershel model and it was found that the R_{ct} value was further reduced to 97.1 Ω when compared to the mono-electrocatalyst counterparts. This indicates that the presence of FeOOH and NiOOH could present a synergistic effect that further reduces the charge carrier transfer resistance and enhances the charge carrier transfer across the interface of electrode/electrolyte.

To further validate the EIS analysis, the charge injection efficiency of the studied photoanodes was evaluated by using aqueous H₂O₂ solution as the scavenger of photogenerated hole. Ideally, the rates of carrier charge transfer to the electrode/electrolyte interface is both thermodynamically and kinetically more facile in the presence of hole scavenger by assuming that the surface recombination of charge carrier is eliminated. In this instance, the difference in the measured photocurrent density with and without H₂O₂ is a direct testament of the charge carrier separation efficiency. From Fig. 5 (b), the measured photocurrent density curve for FTO/V₂O₅/BiVO₄ photoanode with the presence of H₂O₂ shows a very low photocurrent onset potential and a rapid increase in photocurrent density of up to 4.01 mA/cm² at 1.5 V vs Ag/AgCl. The difference in the measured photocurrent density was reduced with the introduction of rGO interlayer in the FTO/V₂O₅/rGO/BiVO₄ photoanode, and this was further reduced with the incorporation of dual-electrocatalyst thin films of FeOOH and NiOOH. This finding implies that the charge carrier recombination is significantly suppressed, and charge carrier separation efficiency is improved by promoting an efficient interfacial photogenerated electron transfer between V₂O₅ and BiVO₄ and storing the photogenerated holes at the NiOOH/electrolyte interface that is necessary to allow OER to take place.

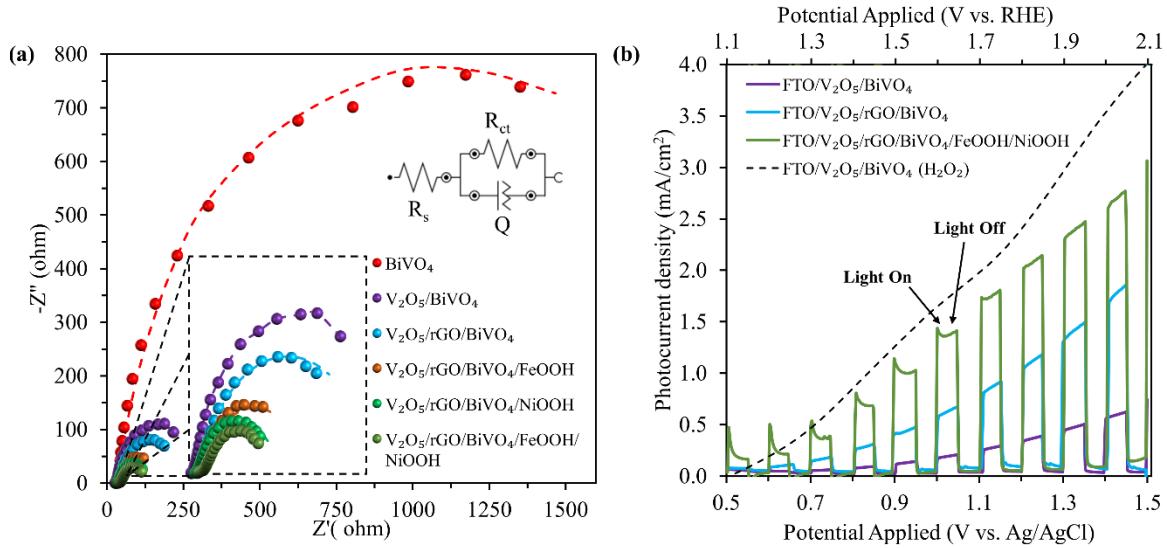


Fig. 5. (a) Nyquist plots of EIS of the studied photoanodes under AM 1.5 G illumination with equivalent circuit (inset). (b) LSV of the FTO/V₂O₅/BiVO₄, FTO/V₂O₅/rGO/BiVO₄ and FTO/V₂O₅/rGO/BiVO₄/FeOOH/NiOOH photoanodes under AM 1.5 G illumination with and without H₂O₂ as a hole scavenger.

Finally, the photostability of the novel hierarchical dual-electrocatalysts configuration photoanode is crucial for practical and sustained H₂ gas evolution from the solar-driven PEC water splitting reaction. Fig. 6 shows the chronoamperometry curves recorded at different applied potential of 0.8 V, 0.9 V and 1.0 V for FTO/V₂O₅/BiVO₄, FTO/V₂O₅/BiVO₄/FeOOH/NiOOH and FTO/V₂O₅/rGO/BiVO₄/FeOOH/NiOOH photoanodes with duration of up to 1,800 s. From Fig. 6, it is evidenced that the photostability of FTO/V₂O₅/BiVO₄ photoanode is comparatively low with its photocurrent densities are decaying in the range of 66.6-73.9% for the applied potential range of 0.8-1.0 V. Recently, Lee D.K. and Choi K.S. have reported that the dissolution of V⁵⁺ and the accumulation of photogenerated holes could initiate the photocorrosion of BiVO₄ [40]. It was, however, with the presence of FeOOH and NiOOH electrocatalyst thin films on FTO/V₂O₅/BiVO₄ photoanode, the photocurrent decay rate was reduced owing the additional functionality of FeOOH/NiOOH layer as a protection layer in preventing the BiVO₄ from direct contact with electrolyte. Thus, the photocorrosion of BiVO₄ can be prevented even if both the photogenerated electrons and holes are available at the surface of BiVO₄. Results showed that the dual-electrocatalysts configuration photoanode was effective even at lower potentials. When a high potential is applied on the dual-electrocatalysts configuration photoanode, some

photogenerated holes are accumulated in the NiOOH thin film that can be scavenged into the oxidation cycle of $\text{Ni}(\text{OH})_2/\text{NiOOH}$ and further destabilise the photoanode [19]. Additionally, it was found that the presence of rGO interlayer in between V_2O_5 and BiVO_4 in the FTO/ V_2O_5 /rGO/ BiVO_4 /FeOOH/NiOOH photoanode can further enhance the photostability of the photoanode.

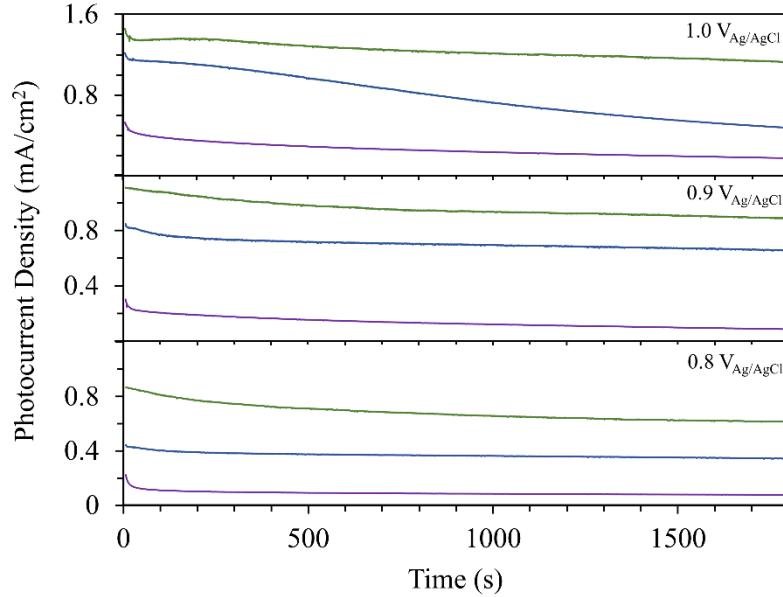


Fig. 6. Comparison of recorded chronoamperometry at different applied potential for FTO/ V_2O_5 / BiVO_4 (Green), FTO/ V_2O_5 / BiVO_4 /FeOOH/NiOOH (Blue) and FTO/ V_2O_5 /rGO/ BiVO_4 /FeOOH/NiOOH (Purple) photoanodes.

Based on the overall results and discussion, three possible charge carrier transfer mechanisms in FTO/ V_2O_5 /rGO/ BiVO_4 photoanodes without electrocatalyst, with mono- and dual-electrocatalyst are proposed and elucidated in Fig. 7. Upon light irradiation of the FTO/ V_2O_5 /rGO/ BiVO_4 photoanode, photogenerated charge carriers will only be generated simultaneously in the CB of BiVO_4 and V_2O_5 . The photogenerated charge carriers will be transferred between BiVO_4 and V_2O_5 through the conventional heterojunction mechanism. Whilst the photoinduced electrons in CB of BiVO_4 will be injected into the CB of V_2O_5 , and the photogenerated holes in VB of V_2O_5 will be extracted and transferred to the VB of BiVO_4 . Therefore, the rate of interfacial charge carrier transfer between BiVO_4 and V_2O_5 is a crucial aspect for mitigating the recombination of electron-hole pairs. With the formation of C-Bi bond between BiVO_4 and rGO interlayer, the lifetime of the photoinduced electrons from CB of

BiVO_4 is prolonged as well as enhancing the electronic transmission performance across the FTO/ $\text{BiVO}_4/\text{V}_2\text{O}_5$ heterojunction structure. However, the photocurrent generation of FTO/ $\text{V}_2\text{O}_5/\text{rGO}/\text{BiVO}_4$ photoanode is still lower than that of the photocurrent generated with the presence of hole scavenger (i.e. H_2O_2). This is due to the accumulation of photogenerated holes at the interface states formed at the $\text{BiVO}_4/\text{electrolyte}$ junction, which serves as the recombination center in promoting surface recombination of electron-hole pairs. Through this study, it can be seen that the issue with the accumulation of photogenerated holes can be inhibited through the introduction of FeOOH electrocatalyst on the FTO/ $\text{V}_2\text{O}_5/\text{rGO}/\text{BiVO}_4$ photoanode. The role of FeOOH electrocatalyst is to enhance the photogenerated holes transfer by harvesting them at the VB of BiVO_4 and proceed by the water oxidation reaction. When the rate of interfacial photogenerated holes transfer for water oxidation is slower than the rate of photogenerated holes inflowing into the FeOOH electrocatalyst thin film, however, this will also lead to the partial accumulation of photogenerated holes at the FeOOH and $\text{BiVO}_4/\text{FeOOH}$ junction and causing surface recombination at BiVO_4 . From this study, it can be seen that the slow water oxidation kinetics can be overcome by introducing an additional layer of NiOOH electrocatalyst thin film on FeOOH to serve as the main water oxidation layer. During the water oxidation, the oxidation state of NiOOH will change from Ni^{3+} to a higher state of Ni^{4+} by extracting the accumulated photogenerated holes from FeOOH. Subsequently, the Ni^{4+} state is reduced to Ni^{2+} by obtaining electrons from H_2O to produce O_2 . Therefore, it can be clearly confirmed that the proposed strategy of utilising a dual-electrocatalyst configuration is able to suppress high surface charge carrier recombination limitation of BiVO_4 through a two-step extraction of photogenerated holes from BiVO_4 to FeOOH to NiOOH.

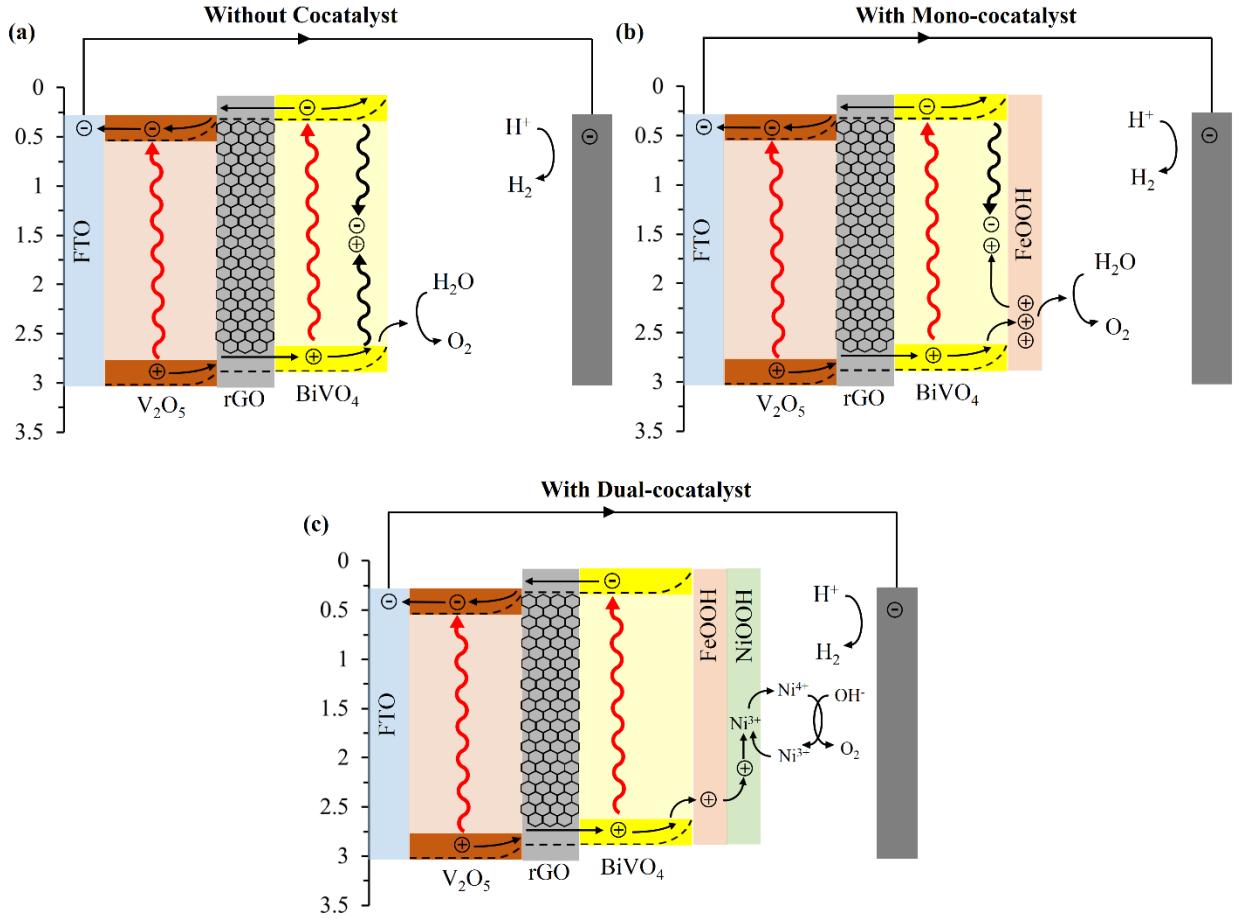


Fig. 7. Schematic of proposed interface charge carrier transfer mechanism for FTO/V₂O₅/rGO/BiVO₄ photoanode (a) without electrocatalyst, (b) with mono-electrocatalyst and (c) with dual-electrocatalyst of under AM 1.5 G illumination for solar-driven PEC water splitting.

4. Conclusion

In this study, we have demonstrated the functionality of rGO interlayer and dual-electrocatalyst thin films as effective photogenerated electron collector and photogenerated hole extractor to suppress surface charge recombination in a novel hierarchical heterojunction photoanode structure, respectively. The dual-electrocatalyst configuration photoanode of FTO/V₂O₅/rGO/BiVO₄/FeOOH/NiOOH exhibited a significantly enhanced PEC performance due to its ability to suppress high surface charge carrier recombination limitation of the hierarchical heterojunction photoanode through a two-step extraction of photogenerated holes from BiVO₄ to FeOOH to NiOOH. The LSV analysis clearly indicated that the FTO/V₂O₅/rGO/BiVO₄/FeOOH/NiOOH photoanode achieved a remarkable photocurrent

density of 3.06 mA/cm² at 1.5 V vs Ag/AgCl, which is 12-fold and 1.5-fold higher than that of FTO/BiVO₄ and FTO/V₂O₅/rGO/BiVO₄ photoanodes as well as lowering and cathodically shifting the onset potential by 0.5 V to a final onset potential of 0.2 V. Through the EIS and IMPS analysis, it was proven that the incorporation of photogenerated electron collector and photogenerated hole extractors are favourable in terms of fast charge carrier transfer process across the electrode/electrolyte interface, and a shorter transit time for the photogenerated electrons to be diffused to the counter electrode. Furthermore, it was found that the presence of dual-electrocatalyst thin films of FeOOH and NiOOH could serve as efficient protective layers to seclude the BiVO₄ layer from electrolyte and preventing the anodic photocorrosion of BiVO₄ from occurring. The enhancement in H₂ gas evolution rate for the dual-electrocatalyst configuration photoanode indicating that most of the photogenerated charge carriers were consumed for the solar-driven PEC water splitting. Finally, three possible charge carrier transfer mechanisms in FTO/V₂O₅/rGO/BiVO₄ photoanodes without electrocatalyst, with mono- and dual-electrocatalyst were proposed and elucidated to gain an in-depth understanding on the respective roles of rGO interlayer, FeOOH and NiOOH electrocatalyst thin films and their synergistic effects on enhancing the overall solar-driven PEC water splitting.

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